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# Photodriven hydrogen evolution by molecular catalysts using Al<sub>2</sub>O<sub>3</sub>-protected perylene-3,4-dicarboximide on NiO electrodes†

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The design of efficient hydrogen-evolving photocathodes for dye-sensitized photoelectrochemical cells (DSPECs) requires the incorporation of molecular light absorbing chromophores that are capable of delivering reducing equivalents to molecular proton reduction catalysts at rates exceeding those of charge recombination events. Here, we report the functionalization and kinetic analysis of a nanostructured NiO electrode with a modified perylene-3,4-dicarboximide chromophore (PMI) that is stabilized against degradation by atomic layer deposition (ALD) of thick insulating Al<sub>2</sub>O<sub>3</sub> layers. Following photoinduced charge injection into NiO in high yield, films with Al<sub>2</sub>O<sub>3</sub> layers demonstrate longer charge separated lifetimes as characterized *via* femtosecond transient absorption spectroscopy and photoelectrochemical techniques. The photoelectrochemical behavior of the electrodes in the presence of Co(II) and Ni(II) molecular proton reduction catalysts is examined, revealing reduction of both catalysts. Under prolonged irradiation, evolved H<sub>2</sub> is directly observed by gas chromatography supporting the applicability of PMI embedded in Al<sub>2</sub>O<sub>3</sub> as a photocathode architecture in DSPECs.

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## Introduction

The harvesting and storage of light energy in the chemical bonds of liquid and gaseous fuels has been of increasing interest in recent years.<sup>1–3</sup> One of many promising approaches uses pairs of dye-sensitized electrodes within photoelectrochemical cells (DSPECs) to drive molecular catalysts to perform the two half reactions of water oxidation and hydrogen evolution.<sup>4–6</sup> Incorporation of both light-driven reactions into one efficient system presents many challenges and opportunities to understand photodriven electron transfer events, charge accumulation steps, catalytic mechanisms, and avoidance of degradation pathways within the components of DSPECs. Several designs that are capable of photodriven (or photoassisted) hydrogen evolution combine molecular catalysts with photosensitized nanomaterials in solution,<sup>7–11</sup> or photosensitized electrodes,<sup>12–18</sup> or use semiconductors as light absorbers.<sup>19–27</sup> Mechanistic investigation of dye-sensitized photocathode architectures remains particularly rare,<sup>28</sup> and such work could lead to improvement in the performance of devices. Current device designs suffer from degradation

of the molecular light absorbers over time and losses in efficiency due to charge recombination at rates competitive with charge accumulation and catalysis. New chromophores based on earth abundant elements are also desirable, since the molecular photosensitizers used in the aforementioned device architectures are almost exclusively ruthenium-based, with the exception of only a few organic chromophores.<sup>13,15,29</sup>

We previously demonstrated that a perylene-3,4-dicarboximide (PMI) chromophore (PMI, Fig. 1) is capable of electron injection into nanostructured TiO<sub>2</sub> following photoexcitation and further capable of oxidizing a molecular water oxidation precatalyst.<sup>30</sup> Studies have also demonstrated the utility of PMI-based chromophores for photodriven hole injection into NiO in p-type dye-sensitized solar cells (DSCs),<sup>31–36</sup> which is encouraging for future work on hydrogen evolving photocathodes. One report suggests that no molecular catalyst is necessary for photodriven hydrogen evolution by a chromophore that includes a PMI moiety on NiO at pH 7,<sup>37</sup> and a similar PMI-based chromophore has driven hydrogen evolution by a cubane molybdenum-sulfide cluster in acidic conditions.<sup>29</sup> However, these photosensitizer designs generally require complex synthesis in order to incorporate a donor-acceptor character that extends the lifetime of the charge separated state. PMI can be synthesized from commercially available perylene-3,4:9,10-tetracarboxydianhydride in only four steps, and the monoanhydride opens to form the dicarboxylate when exposed to metal oxide semiconductors for convenient electrode functionalization.<sup>30</sup>

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Fig. 1 Chemical structures of the PMI photosensitizer and the H<sub>2</sub> evolution catalysts.

The application of an Al<sub>2</sub>O<sub>3</sub> tunneling barrier by atomic layer deposition (ALD) before dye loading on a surface has been shown to act as an alternative to complex molecular synthesis by providing the important advantages of slowing back electron transfer between charges in semiconductors and on chromophores and redox shuttles in DSCs.<sup>16,38–46</sup> In DSPECs, slowing charge recombination at the interface is similarly advantageous for efficient charge accumulation and catalysis. We investigate here the use of an ALD layer of varying thickness deposited after dye loading to slow charge recombination between charges in the dye and semiconductor with those on the catalyst.

However, ALD can also serve an additional purpose important in DSPECs. Dye desorption and degradation limit the performance of electrodes fabricated with PMI, since desorption in the acidic operating conditions and oxidative or reductive degradation of organic chromophores under catalytic conditions are some of the most significant limiting factors in the stability of DSPECs.<sup>3,5</sup> We and others have demonstrated that ALD of either TiO<sub>2</sub> or Al<sub>2</sub>O<sub>3</sub> following dye absorption on nanostructured semiconductors can prevent desorption of bound molecules from surfaces in DSCs<sup>44,47–50</sup> and electrodes for water oxidation.<sup>51,52</sup> In addition, we hypothesize that a thicker layer of metal oxide surrounding the PMI molecules can protect the dyes from undesirable degradation side reactions. Meyer and coworkers have recently observed such a stabilization effect by Al<sub>2</sub>O<sub>3</sub> ALD layers over Ru-based dyes and water oxidation catalysts on nanostructured semiconductors.<sup>53</sup>

Here we report the ability of PMI bound to nanostructured NiO electrodes and protected by Al<sub>2</sub>O<sub>3</sub> to drive well-characterized cobaloxime<sup>54,55</sup> and [Ni(P<sup>R</sup><sub>2</sub>N<sup>R</sup><sub>2</sub>)<sub>2</sub>]<sup>2+</sup> (ref. 56 and 57) hydrogen evolution electrocatalysts (Fig. 1). Besides their efficacy in other photodriven systems, these catalysts were selected based on their electrocatalytic hydrogen production at comparable redox potentials (Table 1, Fig. S4<sup>†</sup>). We explore the charge transfer

Table 1 Steady-state optical properties and redox potentials (V vs. Ag/AgCl)

|                               | $E^{00}$ (eV) | [H <sub>2</sub> SO <sub>4</sub> ] (M) | $E_{ox}$ (V) | $E_{red1}$ (V) | $E_{red2}$ (V)     |
|-------------------------------|---------------|---------------------------------------|--------------|----------------|--------------------|
| PMI <sup>a</sup>              | 2.30          | 0.00                                  | 1.34         | −0.79          | −1.05              |
| NiL <sub>2</sub> <sup>b</sup> | —             | 0.00                                  | —            | −0.47          | −0.74              |
|                               | —             | 0.07                                  | —            | —              | −0.45 <sup>c</sup> |
| CoL <sub>2</sub> <sup>b</sup> | —             | 0.00                                  | —            | −0.51          | —                  |
|                               | —             | 0.10                                  | —            | −0.49          | −0.85 <sup>c</sup> |

<sup>a</sup> Measurements on PMI diester in CH<sub>2</sub>Cl<sub>2</sub> for optical expts; in 0.1 M TBAPF<sub>6</sub> in CH<sub>3</sub>CN for redox expts. <sup>b</sup> 1.0 mM Fc, 0.1 M Na<sub>2</sub>SO<sub>4</sub> in 1 : 1 H<sub>2</sub>O : MeCN, [H<sub>2</sub>SO<sub>4</sub>] listed (Fig. S4). <sup>c</sup> Catalytic onset, as the intersection of the line of the catalytic slope with the cyclic voltammogram trace before acid addition.

dynamics and find that the Al<sub>2</sub>O<sub>3</sub> layers not only stabilize the organic chromophores against desorption and degradation but also favor longer charge separated state lifetimes and light-driven hydrogen evolution.

## Experimental

### Synthesis and film preparation

The PMI dye and PMI diester (see structure in ESI<sup>†</sup>),<sup>30</sup> cobaloxime catalyst,<sup>58</sup> and nickel catalyst<sup>57</sup> were prepared following reported procedures. Nanostructured NiO films on conductive fluorine doped tin oxide (FTO) slides were prepared based on a literature procedure<sup>59</sup> and stored in a 110 °C oven until dye loading. To dye functionalize, films were gently shaken in a 0.45 mM solution of PMI in 1 : 3 toluene : methanol protected from light overnight, rinsed with CH<sub>2</sub>Cl<sub>2</sub>, and dried under a nitrogen stream. The NiO|PMI surface was then treated with 0–30 ALD cycles of dimethylaluminum isopropoxide and water to yield NiO|PMI|Al<sub>2</sub>O<sub>3</sub> films, as described in the ESI.<sup>†</sup> Films for femtosecond transient absorption (fsTA) spectroscopy were either sealed under nitrogen with glass slides using UV-curable epoxy in a glove box, or placed in an acidic electrolyte solution of 0.1 M H<sub>2</sub>SO<sub>4</sub> and 0.1 M Na<sub>2</sub>SO<sub>4</sub> in 1 : 1 H<sub>2</sub>O : MeCN in gas-tight cuvettes and purged with argon. The films for photoelectrochemical experiments were attached to stranded conductive wire using conductive silver epoxy (CircuitWorks Chemtronics), which was then covered with non-conductive epoxy (LOCTITE 9340 Hysol) and cured at 110 °C for 10 min.

### Optical spectroscopy

Femtosecond transient absorption (fsTA) spectroscopy experiments were conducted using a regeneratively amplified Ti : sapphire laser system with samples translated in two dimensions and irradiated at 495 nm as previously described.<sup>30,60</sup> Further details and the fitting procedures are provided in the ESI.<sup>†</sup>

### Electrochemical and photoelectrochemical experiments

Electrochemical measurements were performed using a CH Instruments Model 660A or 750E electrochemical workstation.



Measurements on the dye-functionalized films employed the films as the working electrode, a 3.0 mm diameter glassy carbon counter electrode, and an Ag/AgCl (3 M NaCl) reference electrode. Light was applied from two white LEDs (100 mW cm<sup>-2</sup> incident on the sample per LED) covered with 410 nm long-pass filters. Photocatalysis experiments were performed in a sealed cell under argon with a -0.40 V bias applied concurrently with illumination for two hours. The H<sub>2</sub> in the headspace was identified following triplicate injections of 300 μL each into a gas chromatograph. Faradaic efficiencies were calculated from the amount of H<sub>2</sub> in the headspace and the amount of current passed during the experiment.

## Results and discussion

### Steady-state spectroscopy

The films were characterized by UV-Vis spectroscopy to gain information on the physical effect of ALD on the dye molecules (Fig. 2). The absorption spectrum for NiO|PMI films without ALD displays a (0,0) vibronic absorption maximum at 506 nm, a (0,1) band at 485 nm, and a small shoulder around 575 nm. The low energy shoulder is suggestive of dye aggregation<sup>45,61</sup> but is absent after ALD is applied. Thus, we postulate that aggregates should not play a significant role in the photophysics of the ALD-treated films. As the number of cycles of ALD is increased, the signal broadens until by 30 cycles the vibronic structure is no longer distinct and the λ<sub>max</sub> is red-shifted to 522 nm. Increasing to 40 and 50 cycles produces no further spectral change (Fig. S1†). This spectrum is identical to that of the corresponding PMI diester spin coated onto glass but not to that of PMI diester encapsulated in a soft and flexible PMMA matrix (Fig. S2†), which suggests that the change in band shape after ALD could be due to the imposition of structural rigidity on PMI enforced by the surrounding Al<sub>2</sub>O<sub>3</sub>. The red-shift is likely due to an untwisting of the PMI core that is twisted in the free molecule by the presence of the bulky phenoxy groups.<sup>61</sup> It is unlikely that the shift results from a change in dielectric environment, as we have not observed that effect in previous work.<sup>45,47</sup>

In an attempt to predict the Al<sub>2</sub>O<sub>3</sub> thickness with respect to the PMI molecules, the geometry optimized PMI diester

structure was obtained from DFT calculations (B3LYP/6-31G\*) and shows that the maximum height of PMI from the NiO surface cannot be more than 17.5 Å (Fig. S23 and Table S3†). The ALD growth rate on flat surfaces is ca. 1 Å per cycle as determined by ellipsometry, so it was initially anticipated that the Al<sub>2</sub>O<sub>3</sub> layer would fully encapsulate PMI by 20 cycles of ALD. However, we surmise based on the change in band shapes in the absorption spectra between 20 and 30 cycles of ALD, and no further changes thereafter, that only by 30 cycles of ALD is the dye molecule effectively encapsulated in Al<sub>2</sub>O<sub>3</sub>.

The stability of the dye molecules on the surface was also investigated by UV-Vis spectroscopy after the ALD process and after exposure to ambient light and air over 45 days (Fig. S3†). Minimal dye degradation was observed during the ALD treatment, based on the change in shape of the absorption curves, but following ALD, dye degradation does occur over time. Degradation decreases with increasing Al<sub>2</sub>O<sub>3</sub> thickness so that by 30 cycles degradation is negligible over the 45 day period investigated, which is promising for use of ALD-treated NiO|dye films in devices and further supports the assertion that 30 cycles of ALD is sufficient to cover PMI.

### Electrochemistry

In order to examine the energetic driving force for the desired photodriven charge transfer steps, we compare the redox properties of PMI as determined in our previous work with those of the catalysts and with the NiO valence band (Table 1).<sup>30</sup> The NiO valence band is sufficiently low in energy that it is accessible for hole injection from PMI even at low pH (0.52 V vs. Ag/AgCl),<sup>12,62,63</sup> and fast hole injection from similar PMI-based chromophores has been observed previously.<sup>64</sup> The first reduction potentials, which are reversible in the absence of acid and semi-reversible in its presence, and the onsets of catalysis for NiL<sub>2</sub> and CoL<sub>2</sub> were measured by cyclic voltammetry and are reported in Fig. S4† and summarized in Table 1. The first reduction potential of PMI, E<sub>red</sub> = -0.79 V vs. Ag/AgCl, is sufficiently negative to reduce either catalyst by one electron. In the presence of 0.1 M H<sub>2</sub>SO<sub>4</sub>, the catalytic onset for NiL<sub>2</sub> is milder than the first reduction without acid, so PMI should be able to initiate catalysis. The CoL<sub>2</sub> catalyst, however, has a catalytic onset of -0.85 V vs. Ag/AgCl, so catalysis without applied bias, if possible, is expected to be less efficient than for NiL<sub>2</sub>.

### Transient absorption spectroscopy

We have previously reported the fsTA spectroscopic characterization of the excited state decay of the singlet excited state of PMI (<sup>1</sup>\*PMI) on Al<sub>2</sub>O<sub>3</sub>, where neither electron nor hole injection into the semiconductor is energetically accessible.<sup>30</sup> The <sup>1</sup>\*PMI state that is formed upon excitation of Al<sub>2</sub>O<sub>3</sub>|PMI (dry) films is characterized by a ground state bleach and stimulated emission signal at 440 to 600 nm and an excited state absorption with a maximum centered at 675 nm (species A, Fig. S7A†). The subsequent decay of <sup>1</sup>\*PMI along a number of pathways including excimer formation<sup>65</sup> is approximated using a species-associated model in which <sup>1</sup>\*PMI (species A) decays to species

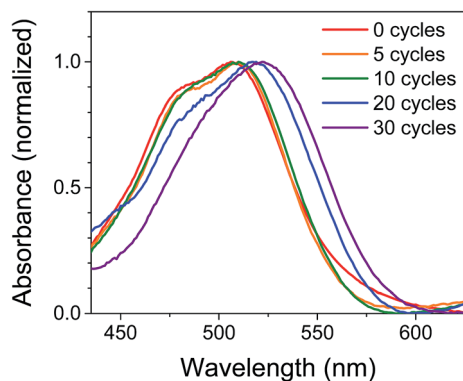


Fig. 2 Normalized UV-Vis absorption spectra of NiO|PMI films treated with 0–30 cycles of Al<sub>2</sub>O<sub>3</sub> ALD. The NiO background is subtracted.



B, which decays to species C, which decays to the ground state (GS). While the spectra for “species B” and “species C” contain contributions from the several species formed along these decay pathways, excimer can be identified by a loss of stimulated emission and red-shift and broadening of the absorptive signal in species C (Fig. S7A†).

NiO|PMI films were then studied by fsTA spectroscopy and, by comparison to the results for Al<sub>2</sub>O<sub>3</sub>|PMI, photodriven hole injection into NiO and subsequent charge recombination were identified for both dry films and films in acidic solution (Fig. 3 and S6–S9†). The lack of significant stimulated emission and excimer signal in the time-resolved spectra for all NiO|PMI samples indicates that nearly quantitative hole injection into NiO occurs very rapidly. The <sup>1</sup>\*PMI spectra (Fig. 3B, species A) and rate of hole injection were identified by global fitting to an A → B → C → D → GS model, where hole injection (A → B) fits to ~0.5 ps for all samples and is likely multiexponential with an

even faster component occurring within the instrument response time (Table S1†).

For the NiO|PMI (dry) film, an excimer population is observed spectrally as a shoulder at 560–600 nm in species B–D (Fig. S9†) and kinetically as a fast rate of decay at 655 nm (Fig. 3C). The shape of the 0.5 ps spectrum for the film without ALD, with a very blue-shifted x-intercept of about 575 nm, indicates that the excimer population is large and begins to form within the instrument response time. The A → B lifetime of 0.6 ± 0.3 ps is not significantly different from the A → B lifetimes for the other samples, so excimer formation likely occurs on a similar timescale and competitively with hole injection. Given the large driving force for hole injection from <sup>1</sup>\*PMI discussed above, it is likely that hole injection also occurs from the excimer state. A much smaller excimer population is also observed in the 500 ps and 5000 ps spectra at 550–600 nm for films without ALD under solvent conditions. The low excimer intensity in these samples likely results from dye interaction with solvent molecules weakening the interchromophore coupling. No excimer is observed for any of the films with 30 cycles of ALD, which indicates that the disaggregation induced by ALD eliminates excimer formation so that hole injection becomes the strongly dominant process.

Following hole injection, the resulting signal is characterized by a ground state bleach centered at 525 nm and an absorptive feature with a λ<sub>max</sub> around 665 nm and is consistent with PMI<sup>•-</sup> (Fig. 3A).<sup>64,66</sup> This signal decays with little change in shape as recombination with holes in NiO occurs (species B–D, Fig. 3B). Recombination is non-exponential, as expected for dye-sensitized semiconductors,<sup>64,67</sup> and could not be adequately fit with fewer than three rates of decay. Consequently, the resulting fit carries a large degree of uncertainty, with values varying only slightly from those used as artificial starting values when initiating the fit. A comparison of the normalized kinetic traces at 655 nm provides more meaningful information (Fig. 3C). Recombination is slowed by the presence of the acidic solution for films with 0ALD, as the PMI molecules experience a more polar environment in solution and thus a lower energy PMI<sup>•-</sup> state.<sup>68</sup> This finding agrees with a previous study that found PMI-sensitized NiO to lie in the Marcus normal region.<sup>64</sup> Thus, dye molecules encased in Al<sub>2</sub>O<sub>3</sub>, which experience an environment of intermediate polarity, display recombination rates between those for 0ALD films with and without solution present. Recombination is only minimally impeded by solution for films with 30ALD because the polarity of the dye environment remains unchanged. This finding indicates that the ALD layer should also shield PMI from catalyst molecules in solution, and slow charge recombination between the reduced catalyst and the surface, as long as the layer is thin enough for initial electron transfer through the layer to the catalyst to occur. However, catalyst reduction could not be directly identified from the fsTA experiments because samples with either NiL<sub>2</sub> or CoL<sub>2</sub> in solution had indistinguishable rates of decay from samples without catalyst (Fig. S10†). We conclude that, while PMI successfully injects holes into NiO in high yield and ALD favors injection over excimer formation, the majority of the electrons on PMI molecules recombine with holes in NiO before



Fig. 3 (A) fsTA spectra of NiO|PMI|30ALD in 0.1 M H<sub>2</sub>SO<sub>4</sub> + 0.1 M Na<sub>2</sub>SO<sub>4</sub> in 1 : 1 H<sub>2</sub>O : MeCN under argon following excitation with a 495 nm laser pulse. (B) Species-associated spectra obtained by a global fit of the fsTA spectra to an A → B → C → D → ground state (GS) model. (C) Normalized single wavelength traces at 655 nm from fsTA results of Al<sub>2</sub>O<sub>3</sub>|PMI (black), NiO|PMI (red), and NiO|PMI|30ALD (orange) dry under nitrogen and NiO|PMI (green) and NiO|PMI|30ALD (blue) in the electrolyte conditions as above.



catalyst diffusion to the surface and subsequent catalyst reduction can occur. All reported photocathodes based on sensitized NiO, including those with surface-bound catalyst, are similarly limited by fast recombination.<sup>12–18,28</sup> We turned to photoelectrochemical techniques to probe the fate of any charge separated states that are sufficiently long-lived to drive photocatalysis.

### Photoelectrochemistry: evidence of hydrogen evolution

Following confirmation that the desired hole injection occurs from PMI into NiO, photoelectrochemical techniques were used to probe the ability of PMI to reduce NiL<sub>2</sub> and CoL<sub>2</sub> catalysts and drive hydrogen evolution. Fig. 4 displays results for linear sweep voltammetry (LSV) experiments on NiO|PMI with 30 cycles of Al<sub>2</sub>O<sub>3</sub> ALD (NiO|PMI|30ALD) in an acidic 1 : 1 H<sub>2</sub>O : MeCN solution (5 mV s<sup>-1</sup> from 0.00 to -0.55 V, 10 s light on/off cycles). In the absence of PMI, photocurrent is negligible (blue), but when PMI is present, the photocurrent is enhanced (black). When the light is turned on, an initial strong photocurrent that rapidly decays results from reduction of the PMI molecules on the surface and local capacitance effects<sup>53</sup> and hole injection that is more rapid than dye regeneration.<sup>69</sup> It is followed by a plateau where hole injection and dye regeneration are in equilibrium. With either NiL<sub>2</sub> or CoL<sub>2</sub> but without acid, the photocurrent is enhanced in a wave-like feature around the first reduction of each catalyst (-0.3 to -0.5 V) (Fig. S11 and S12†), which suggests that photoassisted catalyst reduction from PMI occurs. Upon addition of both acid and 0.5 mM NiL<sub>2</sub> or 0.5 mM CoL<sub>2</sub> to the solution (Fig. 4, red), the photocurrent traces are not simply the sum of those observed for the films with only H<sub>2</sub>SO<sub>4</sub> and those with only catalyst. Instead, the films display a further enhanced photocurrent that increases at increasingly negative

potentials and lacks capacitive features. The stronger photocurrent at more negative biases reflects the higher yield of reduced catalyst resulting from slowed hole recombination at these potentials. The lack of capacitive features indicates that PMI is rapidly regenerated by the catalyst following hole injection into NiO at any applied potential within the range. These changes together indicate that the second reduction of each catalyst and subsequent turnover to produce hydrogen occur.<sup>12,53,69</sup>

Films with 0–20 cycles of Al<sub>2</sub>O<sub>3</sub> ALD and either catalyst also display characteristics of proton reduction for experiments run on duplicate batches of films (Fig. S13–S15†). The shapes of the photocurrent responses for films exposed to either catalyst display no sharp capacitive peak when the light is turned on and higher intensity at more negative bias as observed for the films with 30 cycles of ALD. Some of the films, however, displayed a decrease in absolute photocurrent density in the presence of catalyst relative to those without. The experiments without and with catalyst were performed consecutively on the same films for ease of comparison. Dye degradation and/or desorption at strongly negative potentials,<sup>70</sup> such as those used in the LSV experiments, result in less photocurrent on the second sweep for most films even without catalyst addition (data not shown). In contrast, films that have only been exposed to a -0.40 vs. Ag/AgCl bias, even with catalyst, do not display the photocurrent loss because the PMI molecules are much more stable at these mild potentials (Fig. 6B, S15 and S16†). Gratifyingly, photocurrent is stable over a 10 minute experiment for NiO|PMI|0–30ALD films with either catalyst at this potential (Fig. S19†). Alternatively, degradation at more negative potentials decreases as we increase the number of cycles of Al<sub>2</sub>O<sub>3</sub>. The color of the 30ALD films is preserved throughout the LSV experiment, unlike films with fewer ALD layers, and the photocurrent density on the second sweep is higher relative to the first sweep with increasing ALD layers (Fig. S13†). Thus, we postulate that the shapes of the photocurrent traces suggest successful hydrogen evolution occurs despite a lack of enhanced photocurrent in the presence of catalyst in some instances, and the loss of photocurrent due to degradation can be avoided on our experimental timescale by applying mild potentials and by applying sufficient Al<sub>2</sub>O<sub>3</sub> coverage by ALD. We note that Meyer *et al.* have also observed a decrease in absolute photocurrent for their TiO<sub>2</sub>|dye|ALD|catalyst|ALD samples but were able to assign a change in photocurrent signal shape to an enhanced rate of oxidative catalysis.<sup>53</sup>

### Photoelectrochemistry: analysis of rates

In light of the preceding discussion, we propose that it is most relevant to compare photocurrent response shapes to understand the differences in charge transfer dynamics between samples. These shapes are quantified using the ratio of photocurrent density at the end of a 10 s illumination period during the LSV experiment to that at the beginning ( $I_{-0.10 \text{ V}}/I_{-0.05 \text{ V}}$  or  $I_{\text{light off}}/I_{\text{light on}}$ , Fig. 5). Small ratios for the films without catalyst reflect the strong capacitive current spike, whereas larger current ratios for catalyst-containing samples reflect less

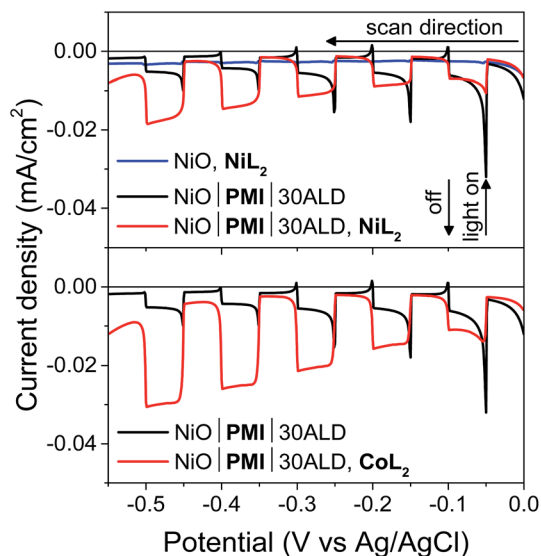


Fig. 4 Linear sweep voltammetry measurements with 10 s light on/off cycles on a NiO working electrode with 0.5 mM NiL<sub>2</sub> (blue) and on a single NiO|PMI|30ALD working electrode without catalyst (black) and with 0.5 mM NiL<sub>2</sub> or 0.5 mM CoL<sub>2</sub> (red) (conditions: 0.1 M H<sub>2</sub>SO<sub>4</sub> and 0.1 M Na<sub>2</sub>SO<sub>4</sub> in 1 : 1 H<sub>2</sub>O : MeCN, 5 mV s<sup>-1</sup>).





observed in the absolute photocurrent densities at the end of 10 s of illumination with increasing Al<sub>2</sub>O<sub>3</sub> thickness especially in the presence of catalyst (Fig. S17†). The NiO|PMI|30ALD, NiL<sub>2</sub> sample in Fig. S17† has low current density and does not match the overall trend, but a comparison with Fig. 4, 6, and S13† suggests that this film is an outlier, potentially due to poor NiO quality. These data suggest that slower recombination and longer-lived charge separated states are achieved by addition of the ALD layer, which favors catalysis. Thus, the overall effect of ALD is to slow undesirable charge recombination events without preventing forward electron transfer.

### Photodriven hydrogen generation

In order to monitor the performance of the films under conditions where hydrogen was expected to form, the electrodes were held at  $-0.40$  V under illumination for 2 h, after which evolved hydrogen was detected by gas chromatography (Fig. S20 and S21†). The applied bias, rather than detracting from the viability of the electrode design, mimics the effect of incorporating the photocathode into a tandem device with a water oxidation photoanode based on TiO<sub>2</sub>, where the conduction band of TiO<sub>2</sub> is at approximately this potential.<sup>13,15</sup> A small but detectable amount of hydrogen was produced by films exposed to light but not to catalyst, in accordance with a report by Tong *et al.* that PMI-based chromophores alone can drive hydrogen evolution.<sup>37</sup> No hydrogen was detected for films with catalyst present in the absence of light. NiO|PMI|30ALD films in the presence of both catalyst and light, however, formed hydrogen with faradaic efficiencies of  $98 \pm 4\%$  and  $60 \pm 10\%$  for NiL<sub>2</sub> and CoL<sub>2</sub>, respectively (Table S2†). A lower hydrogen yield was observed for CoL<sub>2</sub> compared to NiL<sub>2</sub>, despite the larger photocurrents recorded for CoL<sub>2</sub> with shorter irradiation times (Fig. 6), which is likely due to the known instability of CoL<sub>2</sub> to hydrolysis<sup>71</sup> and to the overall higher activity of NiL<sub>2</sub> under these conditions (Fig. S4†). Finally, films without ALD in the presence of NiL<sub>2</sub> produced less hydrogen compared to those with ALD and exhibited a lower faradaic efficiency of  $80 \pm 10\%$ . These films displayed a nearly complete loss of detectable PMI by the end of the two hour experiment, in contrast to the Al<sub>2</sub>O<sub>3</sub>-protected films on which PMI remains (Fig. S22†). This comparison reflects the improvements in stability achieved through incorporation of the Al<sub>2</sub>O<sub>3</sub> layer into the electrode design.

Some high-performing electrodes resulted from variability during the preparation of the underlying NiO. One such champion NiO|PMI|30ALD film with NiL<sub>2</sub> produced about four times the hydrogen with the same faradaic efficiency compared to a typical film (Fig. S20–S21 and Table S2†). From the fsTA results, it is evident that charge recombination between the hole in NiO and the electron on PMI occurs very rapidly and in high yield, as is common for dye-sensitized NiO devices.<sup>12–17</sup> The power conversion efficiency of our high-performing electrode is as a result still very low ( $<1\%$ ). Notably, this champion electrode did produce  $1.82 \pm 0.02$   $\mu\text{mol}$  hydrogen, which corresponds to a turnover number of about 1.5 with respect to catalyst and demonstrates that the hydrogen evolution observed here is indeed catalytic. An improved preparation of NiO, such as

a recently reported treatment to passivate defect sites<sup>72</sup> or a single cycle of ALD before dye loading,<sup>16</sup> would be expected to raise the amplitude of the photocurrent response and overall performance of a device by increasing hole collection.

## Conclusion

We have designed and fabricated a NiO|PMI|Al<sub>2</sub>O<sub>3</sub> ALD photocathode architecture for photodriven hydrogen evolution that incorporates only earth-abundant elements. The PMI chromophores inject holes into NiO in  $<1$  ps in high yield, and ALD of Al<sub>2</sub>O<sub>3</sub> serves to disaggregate PMI and disfavor excimer formation as monitored by steady-state and transient optical spectroscopies. Photoelectrochemical experiments demonstrate successful photodriven reduction of and subsequent hydrogen evolution by two different molecular catalysts in solution. The Al<sub>2</sub>O<sub>3</sub> layers stabilize PMI against desorption and degradation and slow undesirable charge recombination events so that higher photocurrent is achieved. The stabilizing effect further affords photodriven hydrogen evolution at high faradaic efficiencies. These results are promising for further exploration of ALD-embedded organic chromophores in photocathodes for photodriven hydrogen evolution. The findings that ALD of Al<sub>2</sub>O<sub>3</sub> slows charge recombination and stabilizes surface-bound chromophores are expected to apply to other semiconductors that have better inherent charge recombination dynamics and to other catalysts, chromophores, and solution conditions, as long as those solution conditions are selected to allow for stability of the exposed components. Experiments are underway to attach catalysts to the electrode surface in order to improve the rate of catalyst reduction compared to recombination and better probe electron transfer dynamics between the adsorbed dye and the catalyst.

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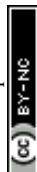
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